



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

June 3, 2026

IGI Report Number

DESCRIPTION

SHAPE AND CUTTING STYLE

MEASUREMENTS

GRADING RESULTS

CARAT WEIGHT

COLOR GRADE

CLARITY GRADE

ADDITIONAL GRADING INFORMATION

POLISH

SYMMETRY

FLUORESCENCE

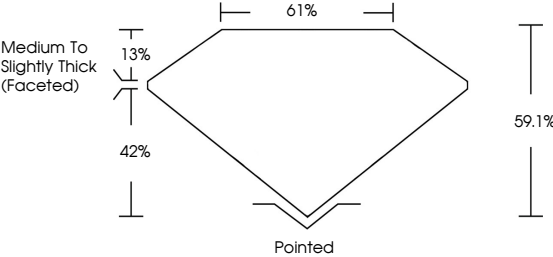
INSCRIPTION(S)

COMMENTS: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

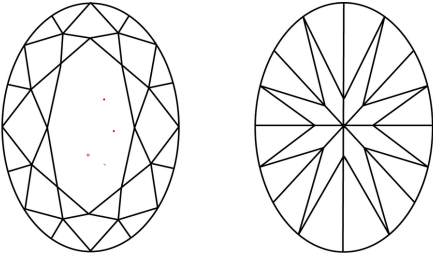
LG805616276

Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included



Sample Image Used

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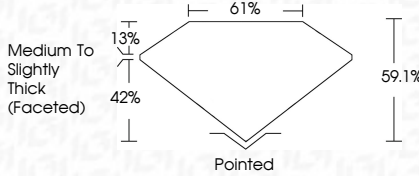
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PROPORTIONS





IGI

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SHAPE AND CUTTING STYLE

CARAT WEIGHT

COLOR GRADE

CLARITY GRADE

DEPTH

TABLE

GIRDLE

CUTTER

POLISH

SYMMETRY

FLUORESCENCE

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4.04 CARATS

G

VS 1

61%

42%

59.1%

Medium to Slightly Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

EXCELLENT

NONE

IGI LG805616276



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